# Study of cluster related effects in n-irradiated Epi-Do and MCz diodes

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Aims ●	$\begin{array}{c} DLTS \to 220^\circ\!\!\mathbb{C} \\ \circ \circ \end{array}$	1A injection-DLTS	1A injection-TSC o	summary & outlook
Aims				

## Topic 1.

• Correlation of current and cluster related defects

# Observation by Fleming et al.

Bistability of cluster related defects → Recovery of cluster defects after injection of forward current

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### Topic 2.

- Characterisation of bistable effect
- Characterisation of cluster related defects

Aims o	$\begin{array}{c} DLTS \to 220^\circ\!\!\mathrm{C} \\ \bullet ^\circ\!$	1A injectio	on-DLTS 1A injection-TSC	summary & outlook

# Isochronal annealing up to 220 °C

## **DLTS** spectra



## MCz

300μm
 3 × 10<sup>11</sup> n/cm<sup>2</sup>

Concentrations obtained via

- Maxima analyses
- fitting
- difference figures

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Aims	$DLTS \rightarrow 220 ^{\circ}C$	1A injection-DLTS	1A injection-TSC	summary & outlook

# Current annealing $\Leftrightarrow$ cluster annealing

## Current at full depletion

-e-Ider

#### 125 100 (Pri) 600 75 -50 25 annealing temperature (°C) Accumulated clusters accumulated cluster defect 2.5x10 iealing (cm<sup>3</sup>) 2 Re10<sup>°</sup> 1.5×10<sup>°</sup> 1.0x10<sup>°</sup> luctor 5.0x10<sup>10</sup> annealing temperature (°C)



Current and cluster annealing are correlated!

## Correlation

Aims o	$\begin{array}{c} \text{DLTS} \rightarrow 220^{\circ}\!$	1A injection-DLTS ●০০০	1A injection-TSC o	summary & outlook
Furthe	r treatment			

# Observation by Flemming et al.

Bistability of cluster related defects after injection of forward current

# Changes in DLTS after injection



## Treatment

- Isochronal annealing step
- Injection of 1A
- Isothermal annealing

## Measurements

- CV/IV
- DLTS/TSC after each step
- capture measurements

Aims	$\begin{array}{c} DLTS \to 220^{\circ}\!$	1A injection-DLTS	1A injection-TSC	summary & outlook
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Stabili	ty of bistabl	e effect		

MCz at 30 minutes at 200 ℃



• Effect is reproducible



• Idep behaves similar

Aims o	$DLTS \rightarrow 220  ^{\circ}C$	1A injection-DLTS 00●0	1A injection-TSC o	summary & outlook			
Bistabl	Bistable effect at higher temperatures						

Annealing steps of 200 ℃, 220 ℃ and 240 ℃



cluster recovery diminished
 enhanced filling of VO and V<sub>2</sub><sup>=/-</sup>



- decrease of E4 and E5 different
- possible correlation with point defects?



MCz



MCz & Epi-Do



- signal increase after annealing
- signal decrease after 20min 1A forward current

 Epi-Do and MCz nearly identical





- injection leads to increase of cluster related defects
- $V_2^{=/-}$  and *VO* suppression

### Differences



Aims o	$\begin{array}{c} DLTS \to 220^\circ\!\!C \\ \circ \circ \end{array}$	1A injection-DLTS	1A injection-TSC o	summary & outlook ●
Summa	arv & outloo	k		

### summary

- Current and cluster related defects are correlated!
- Bistable effect on cluster related defects fully reproducible
- Filling of VO and  $V_2^{=/-}$  reduced by cluster related defects

### outlook

- Annealing temperatures up to 350 ℃
- Characterisation of bistable effect
- Possible correlation of annealing point defects and reduction of bistable effect
- Position of Defects in cluster regions